

Transmitted herewith for filing is the Patent Application of:

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METHOD TO IMPROVE PLANARITY OF ELECTROPLATED COPPER

Enclosed ar	e:					7548 U 10/763	
x <u>2</u>	2 sheets of drawing(s) - formal.						
X A	An assignment of the invention to Taiwan Semiconductor Manufacturing Co.						
A	An associate power of attorney Applicant claims small entity status						
R	Request & Certification under 35 USC 122(b)(2)(b)(i)						
The filing for	ee has been c	alculated as shown be	low:				
		(Col. 1)	(Col. 2)	OTHER THAN	A SMALL ENTITY		
FOR:		NO. FILED	NO. EXTRA	RATE	FEE		
BASIC F	EE	><	><		\$ 770.		
TOTAL (39 -2 0=	19	x 18 =	\$ 342.		
INDEP C		5 -3=	2	x 86 =	\$ 172.		
				SUB TOTAL	\$ 1,284.		
				ASSIGNMENT	\$40.		
	TOTAL						
X P	Please charge my Deposit Account No. 19-0033 in the amount of \$ 1,324. A duplicate copy of this sheet is enclosed.						
x T	The Commissioner is hereby authorized to charge payment of the following fees associated with this communication or credit an						
overpayment to Deposit Account No. 19-0033. A duplicate copy of this sheet is enclosed. X Any additional filing fees required under 37 CFR §1.16.							
	X Any patent application processing fees under 37 CFR §1.17.						
	311 (A) 11 (A) 1						

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I hereby certify that this correspondence is being deposited with the United States Postal Service as Express Mail in an envelope addressed to Assistant Commissioner of Patents, Alexandria, VA, 22313-1450. Applicant and/or Attorney requests the date of deposit as the Filing Date.

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